



FORM PTO-1449

LIST OF PATENTS AND PUBLICATIONS  
FOR APPLICANT'S INFORMATION  
DISCLOSURE STATEMENT

ATTY. DOCKET 10936-66

SERIAL NO. 10/019,858

APPLICANT Hideki Kitamura et al

FILING DATE November 9, 2001

GROUP 1752

FOR Semiconductive Polyvinylidene Fluoride Resin Composition

## UNITED STATES LETTERS PATENT

		DOCUMENT NUMBER							DATE	NAME	CLASS	SUB CLASS
<i>mk</i>	aa	3	7	0	3	5	6	9	Nov. 21, 1972	Wolkowicz		
<i>mk</i>	ab	3	8	2	9	4	0	8	Aug. 13, 1974	Wolkowicz		
<i>mk</i>	ac	4	0	1	3	5	3	1	Mar. 22, 1977	Nakamura et al		

## FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER							DATE	COUNTRY	CLASS	SUB CLASS
<i>mk</i>	ac	51-	1	1	1	3	3	7	Oct. 1, 1976	Japan <i>No Ab</i>		
<i>mk</i>	ad	47-	3	8	3	5			Feb. 24, 1972	Japan <i>No Ab</i>		
<i>mk</i>	ae	51-	3	2	3	3	0		Mar. 18, 1976	Japan (w/English abstract)		
<i>mk</i>	af	51-	1	1	0	6	5	8	Sep. 30, 1976	Japan (w/English abstract)		
<i>mk</i>	ag	54-	1	2	7	8	7	2	Oct. 4, 1979	Japan (w/English abstract)		
<i>mk</i>	ah	60-	1	7	7	0	6	4	Sep. 11, 1985	Japan (w/English abstract)		
<i>mk</i>	ai	61-	7	2	0	6	1		Apr. 14, 1986	Japan (w/English abstract)		
<i>mk</i>	aj	55-	2	6	9	7	3		Jul. 17, 1980	Japan (w/English abstract)		
<i>mk</i>	ak	8-	2	7	2	2	0	8	Oct. 18, 1996	Japan (w/English abstract)		
<i>mk</i>	al	8-	0	5	9	9	4	0	Mar. 5, 1996	Japan (w/English abstract)		
<i>mk</i>	am	7-	0	0	3	1	0	0	Jan. 6, 1995	Japan (w/English abstract)		
<i>mk</i>	an	6-	3	2	9	8	6	1	Nov. 29, 1994	Japan (w/English abstract)		
<i>mk</i>	ao	11-	0	2	9	6	7	8	Feb. 2, 1999	Japan (w/English abstract)		
<i>mk</i>	ap	11-	3	2	3	0	5	2	Nov. 26, 1999	Japan (w/English abstract)		

OTHER ART (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

779959.01

*Mark* 2/7/04